

Received: April 19, 1989; accepted: June 28, 1989

REACTIONS OF TeF_5OCl WITH FLUOROCARBON IODIDES AND SYNTHESIS OF CF_3OTeF_5

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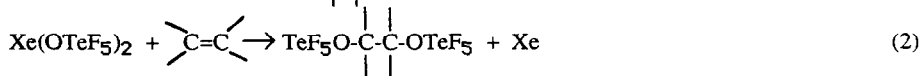
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SUMMARY

The low temperature reaction of TeF_5OCl with the fluorocarbon iodides, CF_3I , $\text{C}_2\text{F}_5\text{I}$, $n\text{-C}_3\text{F}_7\text{I}$, and $i\text{-C}_3\text{F}_7\text{I}$ results in the formation of $\text{R}_f\text{I}(\text{OTeF}_5)_2$ adducts. Except for the trifluoromethyl derivative these are stable, colorless compounds. The trifluoromethyl adduct decomposes above -78°C to give the previously unknown CF_3OTeF_5 . The perfluoroethyl and n -propyl adducts decompose at 120°C or under UV radiation giving $\text{C}_2\text{F}_5\text{OTeF}_5$ and $n\text{-C}_3\text{F}_7\text{OTeF}_5$, respectively. These reactions constitute a new synthesis of primary R_fOTeF_5 compounds. Attempts to extend this synthesis to secondary fluorocarbon iodides were unsuccessful.

INTRODUCTION

Reactions of TeF_5OX ($\text{X}=\text{Cl},\text{F}$) and $\text{Xe}(\text{OTeF}_5)_2$ with fluoroolefins are direct paths to TeF_5O -substituted fluorocarbons [1-3].



Because of the potentially useful properties of these derivatives it was of interest to investigate additional synthetic approaches, thus broadening the availability of the R_fOTeF_5 compounds. One promising approach involved the displacement of iodine from R_fI compounds

using TeF_5OCl . This technique had previously been successfully employed to produce fluorocarbon fluorosulfates by the displacement of halogen from R_fHal species using ClOSO_2F [4,5].

EXPERIMENTAL

Volatile materials were manipulated in a stainless steel vacuum line equipped with Teflon FEP U-traps, 316 stainless steel bellows-seal valves, and a Heise Bourdon tube-type gauge. The reactions were usually conducted in stainless steel cylinders. Infrared spectra were recorded on a Perkin Elmer Model 283 spectrophotometer using cells equipped with AgBr windows. Raman spectra were recorded at ambient temperature on a Cary Model 83 spectrophotometer with the use of the 488-nm exciting line of an Ar ion laser, and a premonochromator for the elimination of plasma lines. To avoid decomposition, the Raman spectrum of the yellow solid, $\text{I}(\text{OTeF}_5)_3$, was recorded at -140°C on a Spex Model 1403 spectrophotometer using the 647-nm exciting line of a Kr ion laser. Sealed quartz tubes, 3mm OD, or Pyrex mp capillaries were used as sample containers. ^{19}F NMR spectra were recorded at 84.6 MHz on a Varian Model EM390 spectrometer with internal CFCl_3 as a standard with negative chemical shifts being upfield from CFCl_3 . Literature methods were used to prepare TeF_5OCl [6]. The fluorocarbon iodides were commercial products (PCR Research Chemicals and Columbia Organic Chemicals) which were stirred with Cu turnings and/or distilled before use.

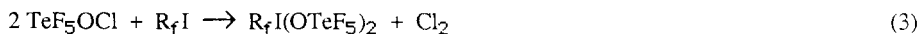
$\text{TeF}_5\text{OCl-R}_f\text{I}$ Reactions. A tared cylinder was cooled to -196°C and measured quantities of R_fI and TeF_5OCl were successively condensed in. The closed cylinder was placed in a dewar containing a liquid N_2 -dry ice slush and this was allowed to warm slowly from -196 to -78°C in a dry ice chest. Monitoring the progress of the reaction at -78°C was accomplished by removing and measuring the evolved Cl_2 or other products volatile at -78°C . After a period of time at -78°C , the reaction mixtures were warmed slowly to ambient temperature to complete the oxidative addition reaction. For CF_3I the resulting adduct was unstable and decomposed above -78°C to give CF_3OTeF_5 (trapped at -126°C on fractionation) and other products. For the other fluorocarbon iodides, all volatile materials were removed at room temperature. In the cylinders remained the colorless addition compounds of composition, $\text{R}_f\text{I}(\text{OTeF}_5)_2$. These were low melting solids or liquids, $\text{C}_2\text{F}_5\text{I}(\text{OTeF}_5)_2$, $30\text{-}31^\circ\text{C}$; $n\text{-C}_3\text{F}_7\text{I}(\text{OTeF}_5)_2$, $49\text{-}51^\circ\text{C}$, and $i\text{-C}_3\text{F}_7\text{I}(\text{OTeF}_5)_2$, $16\text{-}17^\circ\text{C}$.

$\text{R}_f\text{I}(\text{OTeF}_5)_2$ Decomposition Reactions. In the dry box, a tared cylinder was loaded with a weighed amount of the $\text{R}_f\text{I}(\text{OTeF}_5)_2$ compound. The cylinder was then evacuated, closed and placed in an oven at $115\text{-}120^\circ\text{C}$ for several hours. After recooling to ambient temperature, the contents of the reactor were separated by fractional condensation, measured, and identified by their infrared and ^{19}F NMR spectra. In addition to the R_fOTeF_5 product

generally obtained (see text), the significant volatile products were R_fI and some R_fF . Lesser amounts of TeF_6 and TeF_5OTeF_5 [7] were sometimes encountered. Left behind in the cylinder was crude $I(OTeF_5)_3$ identified by infrared and Raman spectroscopy [8] and usually present in 80-90% yield based on the disproportionation reaction shown below. For the photolytic decomposition of $R_fI(OTeF_5)_2$, Pyrex reactors were loaded in the dry box, evacuated, and irradiated with a Hanovia 100W Utility Lamp. In addition to $I(OTeF_5)_3$, the photolysis products contained variable amounts of the coupling product R_fR_f , and for $i-C_3F_7I(OTeF_5)_2$ isomers of C_6F_{14} and C_3F_7I .

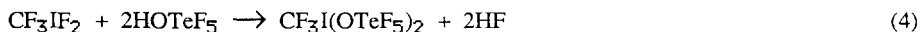
RESULTS AND DISCUSSION

The reaction of TeF_5OCl and R_fI compounds occurs at low temperature in high yield according to (3).



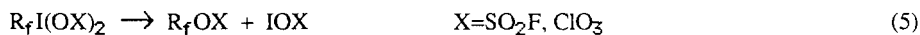
$R_f = CF_3, C_2F_5, n-C_3F_7, \text{ and } i-C_3F_7$

These $R_fI(OTeF_5)_2$ compounds are new compounds, except for the CF_3 - derivative. The latter has previously been reported [9] from the ligand exchange reaction in (4)

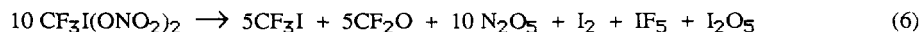


which required a large excess of $HOTeF_5$ and a solvent to obtain complete conversion.

Data on the $R_fI(OTeF_5)_2$ formation reaction (3) are summarized in Table I. Except for $CF_3I(OTeF_5)_2$, these oxidative addition products are all stable at ambient temperature and are low melting solids or a liquid. In analogy, the hypochlorites $ClOSO_2F$ [5], $ClOClO_3$ [10], and $ClONO_2$ [11] also react with fluorocarbon iodides to give the corresponding iodine III adducts in high yields. However, these compounds are generally not stable at ambient temperature. The fluorosulfate [5] and perchlorate [10] decompose according to (5)



whereas the nitrate [11] decomposes in a multistep reaction summarized by equation (6).



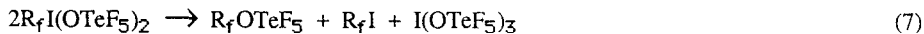
Thus, it appears that the $R_fI(OTeF_5)_2$ compounds are another example of the ability of the TeF_5O - group to stabilize relatively unstable oxidation states [12].

TABLE I
 $R_fI(O\text{TeF}_5)_2$ synthesis and decomposition data

R_fI Type Compd., mmol	TeF_5OCl mmol	Temp. max. °C	Time	$R_f-O\text{TeF}_5$ Product	Percent Yield ^a	Other Products
CF_3I , 0.91	1.85	-78	4d	$\text{CF}_3\text{I}(\text{O}\text{TeF}_5)_2$	I	~80 Cl_2 , CF_4 , TeF_6
$\text{C}_2\text{F}_5\text{I}$, 1.10	2.58	25	3d	$\text{C}_2\text{F}_5\text{I}(\text{O}\text{TeF}_5)_2$	II	Cl_2 , TeF_5OCl , TeF_5OH
$n\text{-C}_3\text{F}_7\text{I}$, 2.56	5.62	25	2d	$n\text{-C}_3\text{F}_7\text{I}(\text{O}\text{TeF}_5)_2$	III	Cl_2 , TeF_5OCl , TeF_5OH
$i\text{-C}_3\text{F}_7\text{I}$, 2.56	4.73	25	2d	$i\text{-C}_3\text{F}_7\text{I}(\text{O}\text{TeF}_5)_2$	IV	Cl_2 , TeF_5OCl , TeF_5OH
I, ~0.7		25	2h	$\text{CF}_3\text{O}\text{TeF}_5$	17	CF_3I , CF_4 , $(\text{TeEt}_2\text{O})_n$ $\text{I}(\text{O}\text{TeF}_5)_3$
II, 0.24		115	21h	$\text{C}_2\text{F}_5\text{O}\text{TeF}_5$	78	$\text{C}_2\text{F}_5\text{I}$, $\text{I}(\text{O}\text{TeF}_5)_3$
III, 0.30		115	26h	$n\text{-C}_3\text{F}_7\text{O}\text{TeF}_5$	30	$n\text{-C}_3\text{F}_7\text{I}$, C_3F_8 , TeF_6 , $\text{TeF}_5\text{O}\text{TeF}_5$, $\text{I}(\text{O}\text{TeF}_5)_3$
III, 0.37		25, UV	18h	$n\text{-C}_3\text{F}_7\text{O}\text{TeF}_5$	77	$n\text{-C}_3\text{F}_7\text{I}$, C_6F_{14} , $\text{I}(\text{O}\text{TeF}_5)_3$
IV, 0.66		120	10h			$i\text{-C}_3\text{F}_7\text{I}$, $\text{CF}_3\text{C}(\text{O})\text{CF}_3$, C_6F_{14} , $\text{TeF}_5\text{O}\text{TeF}_5$, $\text{I}(\text{O}\text{TeF}_5)_3$
IV, 0.53		25, UV	16h			C_6F_{14} , $i\text{-C}_3\text{F}_7\text{I}$, $\text{I}(\text{O}\text{TeF}_5)_3$

^a Yield based on the limiting reagent and for the decomposition reactions on the stoichiometry: $2 R_f\text{I}(\text{O}\text{TeF}_5)_2 \rightarrow R_f\text{O}\text{TeF}_5 + R_f\text{I} + \text{I}(\text{O}\text{TeF}_5)_3$.

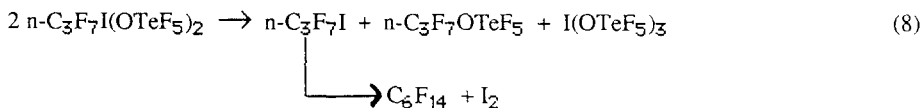
Thermal decomposition of these compounds takes place below 25°C for the methyl compound and at 115-120°C for the ethyl and n-propyl derivatives (7).



$R_f = CF_3, C_2F_5, \text{ and } n-C_3F_7$

The high yields of $I(OTeF_5)_3$ in (7) demonstrates again the stabilizing effects of the TeF_5O- group on I (III). Furthermore, this mode of decomposition contrasts sharply with that noted for reaction (6) and to some extent with that for reaction (5).

The $R_fI(OTeF_5)_2$ compounds can also be decomposed by UV photolysis. For the n-propyl compound reaction (8) was observed.



Except for the secondary decomposition of $n-C_3F_7I$, this process emulates the thermal reaction (7).

For $i-C_3F_7I(OTeF_5)_2$, neither photolysis nor thermal decomposition resulted in the formation of any R_fOTeF_5 derivative. It is noteworthy that the decomposition of $i-C_3F_7I(OSO_2F)_2$ and $i-C_3F_7I(OCIO_3)_2$ also did not produce $i-C_3F_7OSO_2F$ [5], or $i-C_3F_7OCIO_3$ [10], respectively. Therefore, it appears that for $X=TeF_5, SO_2F,$ or ClO_3 , the R_fOX synthesis from R_fI and $ClOX$ is limited to primary R_fI compounds.

Table II lists the ^{19}F NMR data for the new compounds. Data for $C_2F_5OTeF_5$ and $n-C_3F_7OTeF_5$, prepared by other routes, have previously been reported [1]. The TeF_5O- groups give rise to AB_4 type spectra which are very similar for compounds of the same structural type. For CF_3OTeF_5 , the observed chemical shifts are within the $A = -49$ to -54 and $B_4 = -38$ to -45 ppm range, found [1-3] for other R_fOTeF_5 moieties. For the $R_fI(OTeF_5)_2$ compounds the observed chemical shifts for the B_4 part are again in this region but the A part is shifted downfield to about -41 ppm. A similar shift of the A resonances from the high to the low field side of the B_4 resonances has also been noted for a series of inorganic TeF_5O- derivatives [13]. This change in the relative shifts of A and B_4 is due to the differences in the bonding environment of the TeF_5O- groups in the $R_fI(OTeF_5)_2$ and R_fOTeF_5 compounds.

TABLE II

 ^{19}F NMR data^a

JHz	
Φ	-41.1A -44.4bB ₄ -68.7b -79.6b
JHz	
Φ	-41.0A -44.6bB ₄ -63.0b -119b -80.8(t of t)
JHz	
Φ	-40.8A -43.4bB ₄ -125.2b -70.5d
JHz	
Φ	-50.2A -44.3B ₄ -51.6qi

^aCFCl₃ internal reference, negative shift being upfield from the reference. Φ = chemical shift, ppm (multiplicity; where b = broad; d = doublet, t = triplet, and qi = quintet. The area ratios measured for these resonances agreed with the given assignments. $J_{125\text{ Te }^{19}\text{ F}} = 3640\text{-}50\text{ Hz}$ for the $\text{R}_f\text{I}(\text{OTeF}_5)_2$ compounds.

For the fluorine on carbon resonances there is remarkably little change in the chemical shifts on going from R_fI to $\text{R}_f\text{I}(\text{OTeF}_5)_2$, except for the CF resonance of the secondary fluorine in the isopropyl compound which is shifted from $\Phi = -149$ in $i\text{-C}_3\text{F}_7\text{I}$ [14] to $\Phi = -125$ in $i\text{-C}_3\text{F}_7\text{I}(\text{OTeF}_5)_2$. This downfield shift might be caused by steric factors.

The vibrational spectra for the $\text{R}_f\text{I}(\text{OTeF}_5)_2$ compounds are given in Table III. In the infrared spectra, strong bands associated with νCF_n ($1320 - 1130\text{ cm}^{-1}$), νCC ($1060 - 850\text{ cm}^{-1}$), and δCF_n ($820 - 785\text{ cm}^{-1}$) motions are characteristic for fluorocarbon species. In addition, strong infrared bands at about 740 , 710 , and 325 cm^{-1} are attributable

TABLE III

Vibrational spectra of $R_fI(OTeF_5)_2$ compounds

Assign.	Obsd. Freq. cm^{-1} (rel. intens.) ^a					
	$C_2F_5I(OTeF_5)_2^b$		$nC_3F_7I(OTeF_5)_2^b$		$iC_3F_7I(OTeF_5)_2^c$	
	IR	Raman	IR	Raman	IR	Raman
vCF	1323 s	1320(0.1)	1320 s	1326(0.6)	1293 s	1300(0.1)
	1245 vs	1235(0.1)	1260 s		1250 s	1250(0.1)
vCC	1132 s	1130(0.2)	1225 s		1162 m	1165(0.2)
			1153 s			
δCF _n			1055 m	1060(1.8)		
			1030 sh		962 m	
v _{as} TeF ₄	890 s	887(0.6)	850 sh		861 m	875(1.2)
			814 w	820(0.5)		
vTeF'	805 s	800(1.0)	786 s	793(1.2)	800 m	800(0.9)p
	732 sh	731(0.6)	730 s	728(1.9)		748(2.3)p
v _{as} TeF ₄	740 s	742(0.9)	740 s	745(0.4)	745 s	
vTeF'	710 s	710(1.9)	710 s	710(2.7)	710 s	715 sh
vsTeF ₄		692(3.3)		695(4.1)		700(4.7)p
vTeO				655(2.1)		
	635 m	643(4.7)	629 m	640(3.0)	630 m	648(5.9)p
		620 sh	625(1.9)			
	583 w		595 m	598(0.8)		
	548 w	545(0.3)	531 m	535(0.3)	543 w	541(0.9)
			512 w			
v _{as} IO ₂	465 ms		453 ms		465 m	
v _s IO ₂		440(4.8)		458(6.6)		455(3.9)p
		382(0.7)		380(1.0)		
		369(1.0)				
		353(0.9)				350(0.5)p
δFTeF ₄	325 s	330(1.0)	325 s	325(1.0)	320 s	327(1.2)dp
δOTeF ₄		305(1.0)		302(1.1)		300(0.6)dp
δ _{as} TeF ₄	265 w	271(0.5)	265 mw			
vCI				265(8.0)		
		240(10)		238(5.0)		238(10)p
δClO ₂		205(1.3)		165(3.7)		190(0.7)p
		135(7.8)		138(10)		135(8.3)p
			112(1.7)			
			92(5.0)			95(3.1)p

^a Uncorrected Raman intensities (peak heights); ^b solid; ^c liquid

to $\nu_{as}\text{TeF}_4$, $\nu\text{TeF}'$, and δFTeF_4 , respectively, of the TeF_5O -group. These assignments are the same as those given for R_fOTeF_5 [1-3] and TeF_5X [15, 16] compounds. Two additional medium to strong intensity infrared bands are present for these compounds at about 630 and 460 cm^{-1} . The higher frequency band is assigned to νTeO which appears in the region $720 - 700\text{ cm}^{-1}$ in $(\text{TeF}_5\text{O})_2\text{R}_f$ compounds [3], at 616 cm^{-1} in TeF_5OF [15], and at 625 cm^{-1} in $\text{I}(\text{OTeF}_5)_3$ [8]. For the 460 cm^{-1} band of the $\text{R}_f\text{I}(\text{OTeF}_5)_2$ compounds, no comparable band was observed in other R_fOTeF_5 or TeF_5X species. This band is then assigned to an iodine oxygen stretching mode which is found at 434 cm^{-1} in $\text{I}(\text{OTeF}_5)_3$ [8].

Raman counterparts are present for many of these strong infrared bands, *i.e.* νCF_n ; νCC ; δCF_n ; $\nu_{as}\text{TeF}_4$; $\nu\text{TeF}'$; and δFTeF_4 , and, as expected, they are relatively weak. For R_fOTeF_5 compounds, a Raman band at 675 cm^{-1} is dominant [3] and arises from $\nu_3\text{TeF}_4$. For the $\text{R}_f\text{I}(\text{OTeF}_5)_2$ compounds, this band appears at about 695 cm^{-1} , but it is no longer the strongest Raman band. The two strongest Raman bands now occur at about $265 - 240\text{ cm}^{-1}$ and at 135 cm^{-1} . For the higher frequency band, an assignment is made as νCl , which occurs at $280 - 260\text{ cm}^{-1}$ in simple R_fI compounds [17] and which is expected to be a very intense Raman band. The intense band at 135 cm^{-1} is attributed to the skeletal bending mode, δClO_2 . This agrees well with the most intense Raman band observed for $\text{I}(\text{OTeF}_5)_3$ at 134 cm^{-1} [8] and which probably arises from the δOIO_2 motion. Medium intensity Raman bands are present corresponding to the νTeO and $\nu_3\text{IO}_2$ motions whose infrared counterparts have been mentioned. Thus all the spectroscopic data, including ^{19}F NMR, are in agreement with the formulation of these materials as $\text{R}_f\text{I}(\text{OTeF}_5)_2$.

The infrared spectrum of CF_3OTeF_5 exhibits bands at $1263(\text{s})$; $1233(\text{s})$; $1192(\text{vs})$; $743(\text{s})$; $710(\text{m})$; and $324(\text{s})\text{ cm}^{-1}$. Comparable νCF_n vibrations are found for CF_3OSF_5 at $1274(\text{s})$, $1243(\text{s})$ and $1202(\text{vs})\text{ cm}^{-1}$ [18]. In the case of $\text{C}_3\text{F}_7\text{OTeF}_5$ its infrared spectrum was previously reported [1] for a 70:30 mixture of *n*- and *iso*- $\text{C}_3\text{F}_7\text{OTeF}_5$. The spectrum of pure *n*- $\text{C}_3\text{F}_7\text{OTeF}_5$ isolated in this study exhibits bands at $1338(\text{w})$, $1250(\text{vs})$, $1229(\text{m})$, $1186(\text{m})$, $1170(\text{m})$, $1010(\text{m})$, $754(\text{s})$, $726(\text{m})$, and $331(\text{m})\text{ cm}^{-1}$.

CONCLUSIONS

It has been found that the reaction of TeF_5OCl with R_fI compounds proceeds at low temperature to furnish $\text{R}_f\text{I}(\text{OTeF}_5)_2$ derivatives in high yield. These adducts were thermally and photolytically decomposed, yielding in the case of the primary fluorocarbon compounds, the corresponding R_fOTeF_5 compounds. This two step sequence represents a new process for preparing R_fOTeF_5 type materials.

ACKNOWLEDGMENT

The authors are grateful for support of this work by the U.S. Air Force Office of Scientific Research under Contract F49620-81-C-0020, and to Dr. L.R. Grant for helpful discussions.

REFERENCES

- 1 C. J. Schack and K. O. Christe, *J. Fluorine Chem.*, 24 (1984) 467.
- 2 C. J. Schack and K. O. Christe, *J. Fluorine Chem.*, 26 (1984) 19.
- 3 C. J. Schack and K. O. Christe, *J. Fluorine Chem.*, 27 (1985) 53.
- 4 A. V. Fokin, Yu. N. Studnev, I. N. Krotovich, L.D. Kuznetsova, and O. V. Verenikin, *Izv. Akad. Nauk SSSR Ser. Khim.* (1979) 748.
- 5 C. J. Schack and K. O. Christe, *J. Fluorine Chem.*, 16 (1980) 63.
- 6 C. J. Schack and K. O. Christe, *J. Fluorine Chem.*, 21 (1982) 393.
- 7 H. Burger, *Z. Anorg. Allg. Chem.*, 360 (1968) 97.
- 8 K. Seppelt, *Chem. Ber.*, 106 (1973) 1920.
- 9 D. Naumann, Research Report of the State of North Rhine-Westfalia, No. 3115, West Germany, Verlag (1982).
- 10 C. J. Schack, D. Pilipovich, and K. O. Christe, *Inorg. Chem.*, 14 (1975) 145.
- 11 D. Naumann, H. H. Heinsen, and E. Lehmann, *J. Fluorine Chem.*, 8 (1976) 243.
- 12 K. Seppelt, *Accts. of Chem. Res.*, 12 (1979) 211.
- 13 K. Seppelt, *Z. Anorg. Allg. Chem.*, 399 (1973) 65.
- 14 C. H. Dungan and J. R. VanWazer, 'Compilation of Reported ^{19}F NMR Chemical Shifts' Wiley-Interscience, New York, 1970.
- 15 C. J. Schack, W. W. Wilson, and K. O. Christe, *Inorg. Chem.*, 22 (1983) 18.
- 16 W. V. F. Brooks, M. Eshague, C. Lau, and J. Passmore, *Can. J. Chem.*, 54 (1976) 817.
- 17 D. A. C. Compton and D. M. Rayner, *J. Phys. Chem.*, 86 (1982) 1628.
- 18 G. Pass and H. L. Roberts, *Inorg. Chem.*, 2 (1963) 1018.